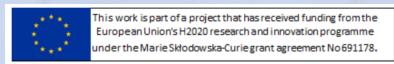
Noise-Induced Performance Enhancement of Variability-Aware Memristor Networks

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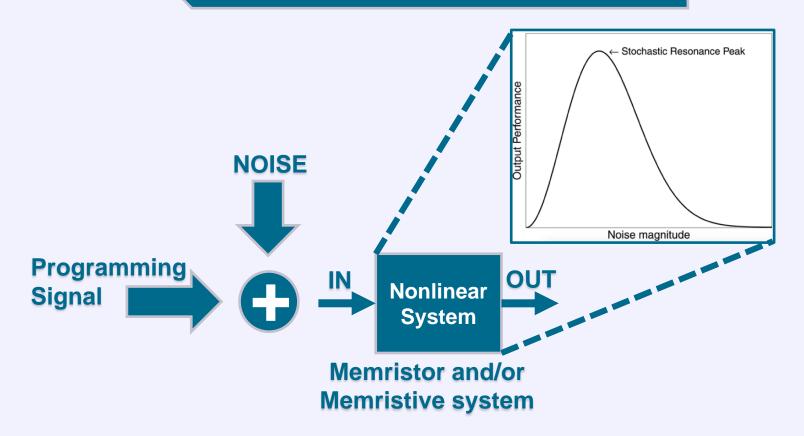
Department d' Enginyera Electrónica

NANOxCOMP - Marie Skłodowska-Curie grant agreement No 691178

Performance Enhancement

"Based on Stochastic Resonance"

Towards the implementation of more robust resistive switching systems



2

Presentation Outline

- Memristor Devices and Applications
- Memristor-based Cell and Memristor Crossbar
- Variability in Memristor Crossbar
- **☞ Stochastic Resonance on Memristance Enhagncement**
- **™** Noise-induced Bit-Error-Rate Reduction
- **Conclusions**

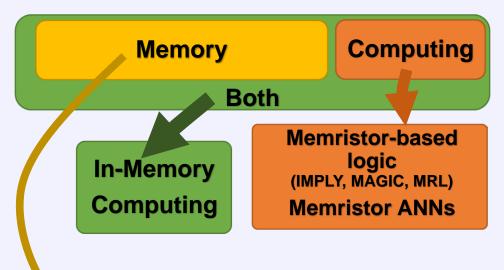
Memristor Devices and Applications

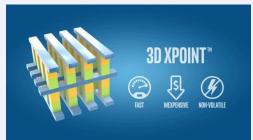
Wide range of devices

State O resistive State 1 conductive Chalcogenide Electrolyte Metal oxide

[Meijer, G.I., Science 319(5870) (mar 2008) 1625–1626] [Intel Corporation: Revolutionizing Memory and Storage] [Kvatinsky, S., Belousov, D., Liman, S., Satat, G., Wald, N., Friedman, E.G., Kolodny, A., Weiser, U.C., IEEE TCAS:II (2014)] [E. Lehtonen, J. H. Poikonen, and M. Laiho, IEEE ISCAS, Seoul, South Korea, May 2012] [Kvatinsky, S., Wald, N., Satat, G., Kolodny, A., Weiser, U.C.,

Wider range of Applications





Friedman, E.G., CNNA 20121

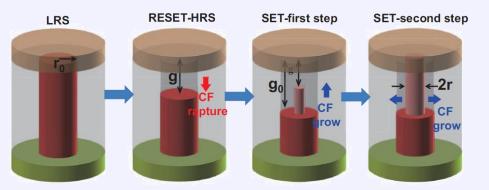
Metal Oxide: Bipolar Filament

Metric	Value	Quality
Scalability	F _{min} < 10nm	✓ ✓
MLC	Possible	✓
3D integration	Feasible	✓ ✓
Fabrication cost	Low	✓
Retention	Long (>10yrs)	✓ ✓
Latency	Medium (0.3-10us)	✓
Power	Medium	✓
Demonstrated Write Endurance	Medium (≤1E10 cycles)	✓
Variability	Problematic	×

[Table BC2.7 in the International Roadmap for Devices and Systems. "Beyond CMOS," 2018.]

Stanford-PKU Metal-Oxide Memristor Model

Conductive Filament Evolution



Conductive Filament Dynamics

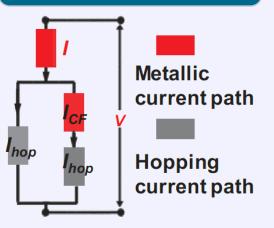
Conductive Filament Construction

$$dg / dt = af \exp \left(-(E_a - \alpha_a ZeE) / k_B T\right)$$

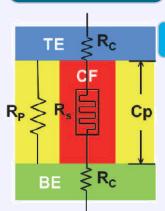
$$dr / dt = \left(\Delta r + \Delta r^2 / 2r\right) f \exp \left(-(E_a - \alpha_a ZeE) / k_B T\right)$$

Conductive Filament Disruption

Currents through the Device



Device Parasitics



 $\min \left\{ \begin{array}{l} dg / dt = af \exp \left(-\left(E_{i} - \gamma ZeV\right) / k_{B}T\right) \\ dg / dt = af \exp \left(-E_{h} / k_{B}T\right) \sinh \left(\alpha_{h} ZeE / k_{B}T\right) \end{array} \right.$

Do not forget the Temperature

$$T = T_0 + IVR_{th}$$

Conductive Filament Variability

$$I_{hop} = I_0 g = \int (dg) dx dt + -\delta g = \chi(t) dt V_{gap} / V_T$$

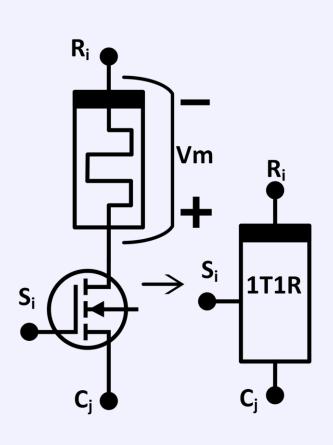
$$r = \int (-dr t)^2 dt_{CF} + \delta dr \times (\chi(t)) dt$$

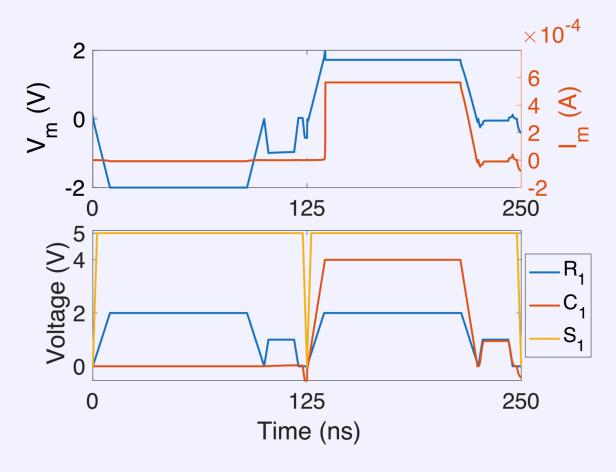
[Li, H., Jiang, Z., Huang, P., Wu, Y., Chen, H. Y., Gao, B., Liu, X. Y., Kang, J. F. & Wong, H. S., DATE 2015]

1T1R Configuration for Memristor Crossbar

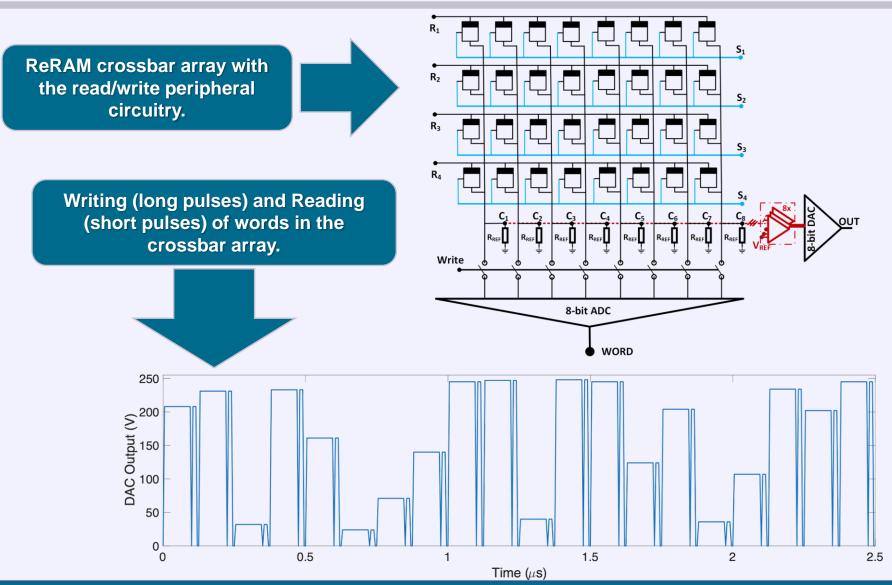
1T1R ReRAM-based Memory Cell

SET and RESET Processes of the ReRAM Cell





ReRAM Crossbar Configuration



SET and RESET variations in the Crossbar Array



Stochastic Resonance

Can noise be a positive factor???

Stochastic Resonance

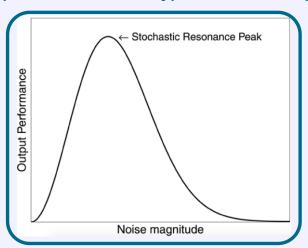
(from the perspective of Engineers):

"An *increase* to the input noise can result in an *improvement* in the output signal-to-noise ratio (SNR)"

Where to find Stochastic Resonance?

- · Earth's climate changes
- · Electronic circuits
- Differential equations
- Lasers
- Neural models
- Physiological neural populations and networks
- · Chemical reactions
- Ion channels
- SQUIDs (superconducting quantum interference devices)
- Ecological models
- Cell biology
- · Financial models
- Psychophysics
- · Carbon nanotube transistors
- Nanomechanical oscillators
- Organic semiconductor chemistry
- Social systems

Performance(noise+nonlinearity)>Performance(nonlinearity)

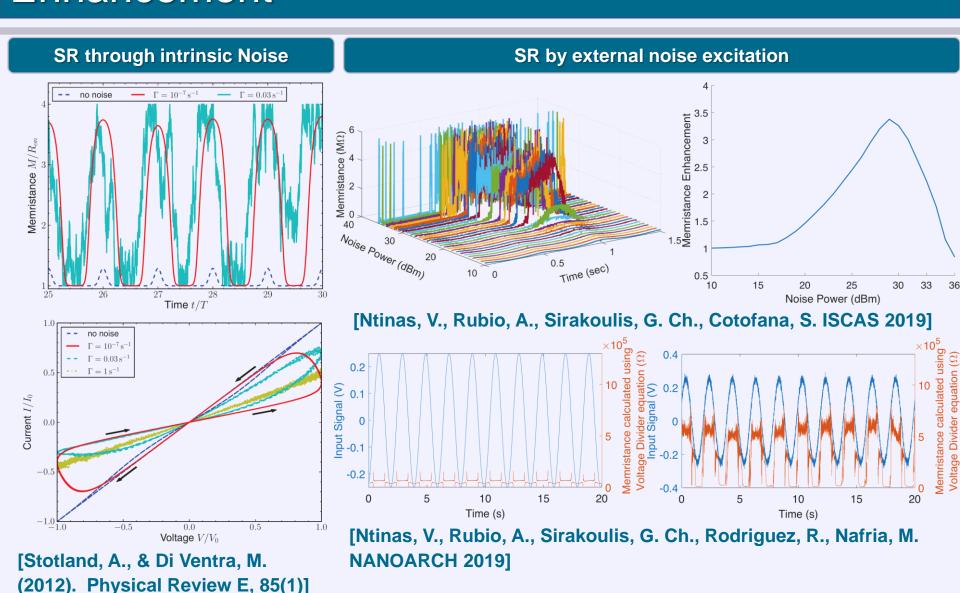


Stochastic Resonance requires:

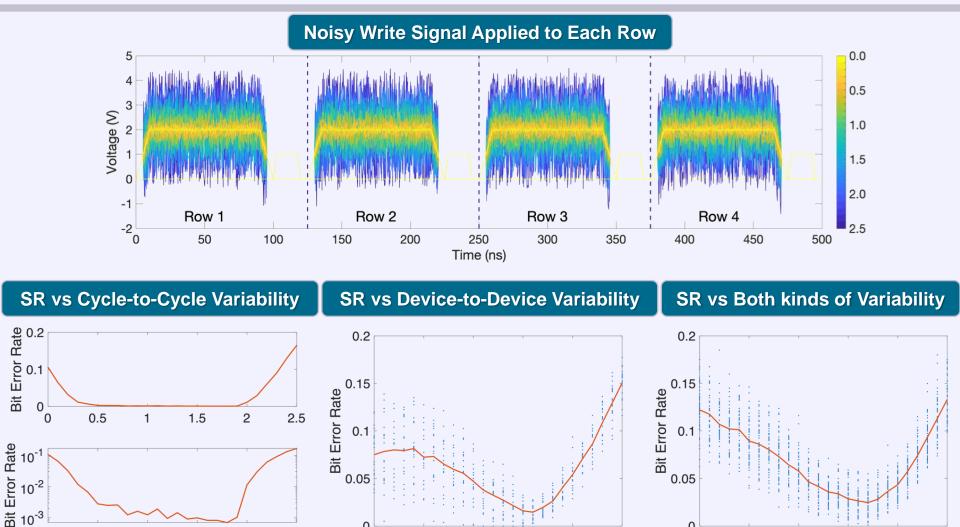
- (a) A form of Threshold
- (b) A driving signal
- (c) A source of noise (inherent or external)

[Gammaitoni, L., Hänggi, P., Jung, P., & Marchesoni, F. (1998). Reviews of modern physics, 70(1), 223.] [McDonnell, M. D., & Abbott, D. (2009). PLoS computational biology, 5(5)]

Stochastic Resonance on Memristance Enhancement



SR-based Performance Enhancement



1.5

Noise Intensity (V)

2

2.5

0

0.5

2

Noise Intensity (V)

2.5

0

0

0.5

2.5

10-3

0

0.5

1.5

Noise Intensity (V)

Conclusions

- High levels of fabricated memristor's variability postpones the scaling of memristor-based memories
- A noisy disturbance delivers reduced Bit-Error-Rate by assisting the writing process of the devices in the Memristor Crossbar Array.

Future Work

- A transistorless Memristor Crossbar configuration will be investigated
- Experimental demonstration of SR-based Performance Enhancement using externally applied white noise

Thank you for your attention

DUTh 29/11/2019 14